

ICMAP 2018

The 7th International Conference on Microelectronics and Plasma Technology

July 24-28, 2018 / Songdo ConvensiA, Incheon, Korea

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Andreas Pflug has studied Physics at University of Hannover and made his Diploma Thesis in 1996 at the Institute for Solar Energy Research Hamelin (ISFH). In the following, he worked at ISFH on modeling surface recombination dynamics in silicon solar cells. Since 2000, he is employed at Fraunhofer Institute for Surface Engineering and Thin Films (IST) where he made his PhD on “Simulation of reactive magnetron sputtering” in 2006. Since 2008, he is head of the group „Simulation“, which is involved in modelling thin film deposition processes.